

Understanding In-Field Performance of REBCO Conductor with Artificial Pinning Centers by Scanning Raman Spectroscopy and 2D-XRD

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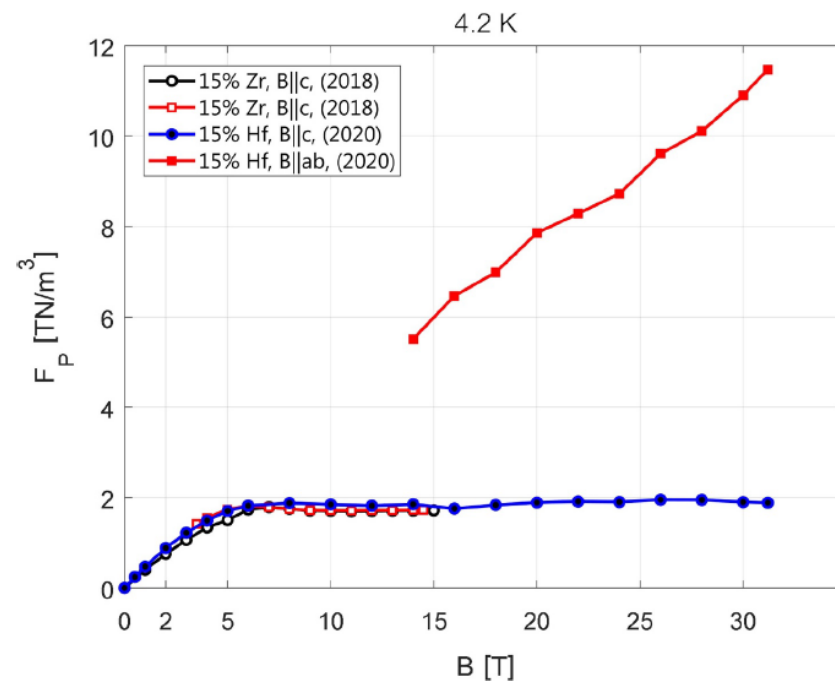
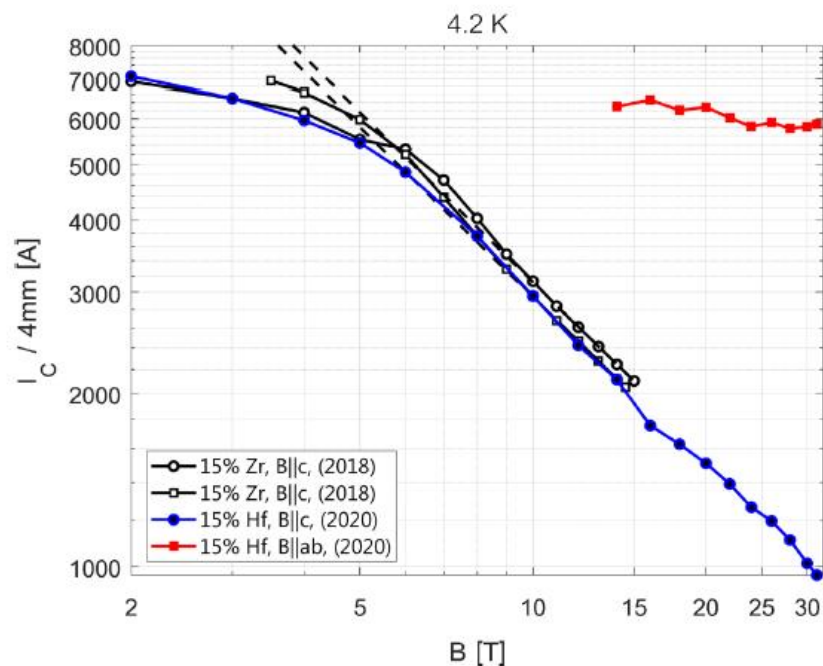
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Funded by:

DE-SC0016220 U.S. Department of Energy, Office of Science – High Energy Physics
DE-AR0001374 from Advanced Research Projects Agency – Energy.

Strong in-field performance can be achieved by combining thick (2-4 μm) REBCO films with optimized BMO pinning centers



- Pinning force plateau of 2 TN/m³ at 4.2 K $B > 5\text{T}$, B||c
- Near-identical performance between 15% Zr and 15% Hf
- At B||ab, near-linear increase in F_p up to 31.2 T

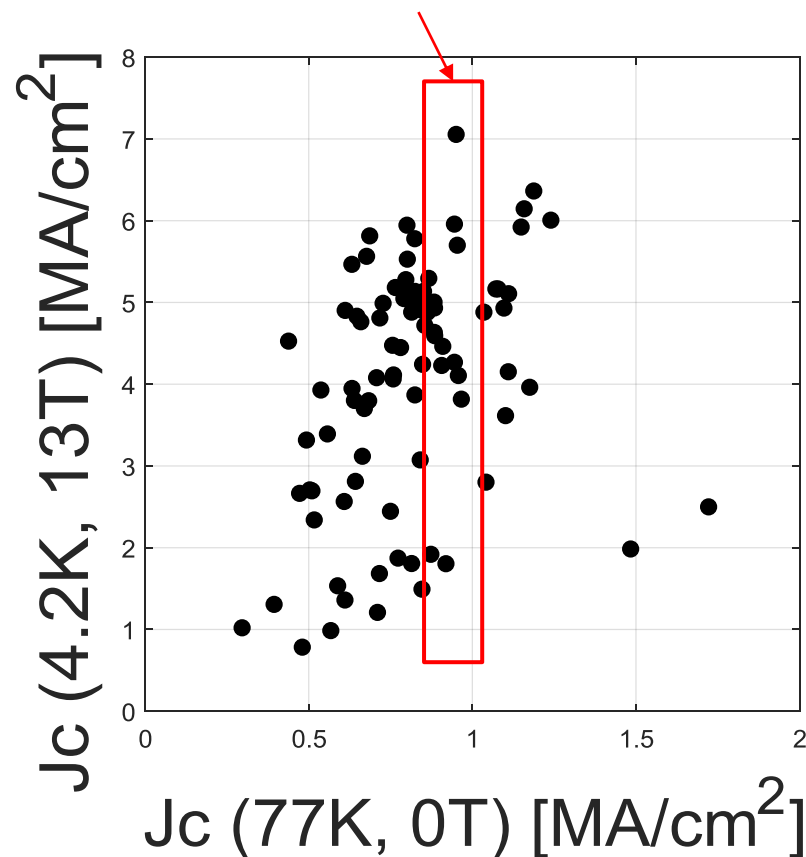
- What determines equilibrium nanorod diameter and density?
- How to quickly evaluate pinning center density over long lengths?

Background

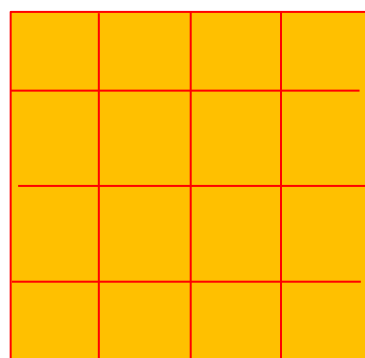
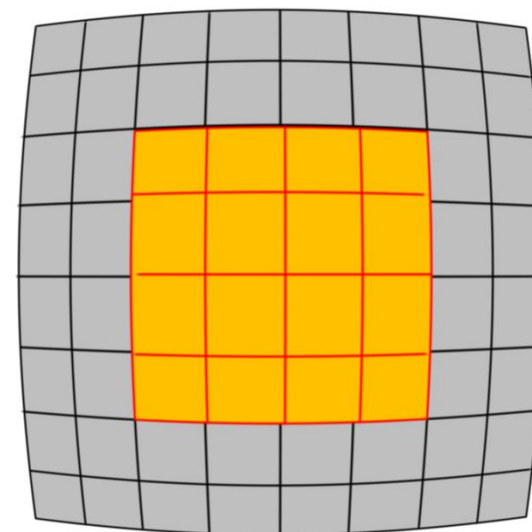
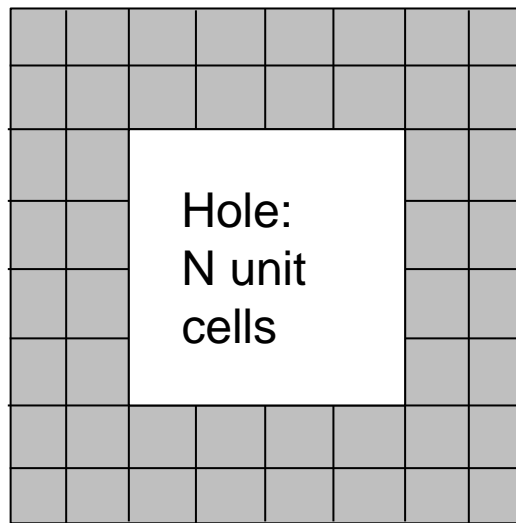
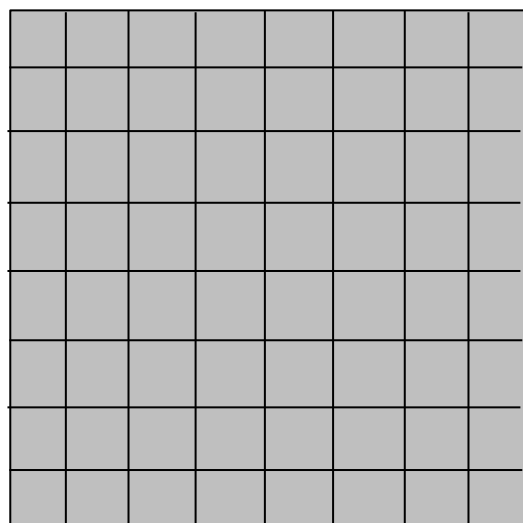
Performance at (77K, 0T) is not indicative of in-field performance at low temperatures and high fields

What influences the large scatter observed, regardless of deposition technique?

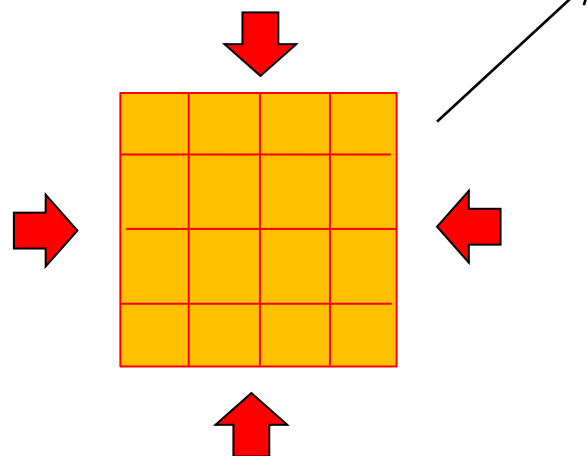
Can we determine performance at (B,T) of interest quickly and non-destructively?



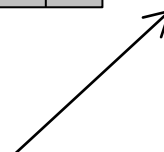
TEM – Nanorod Self-Assembly: Scenario 1



Nanorod:
N unit cells



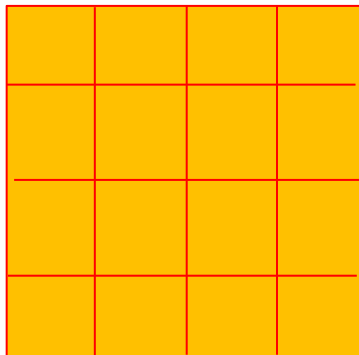
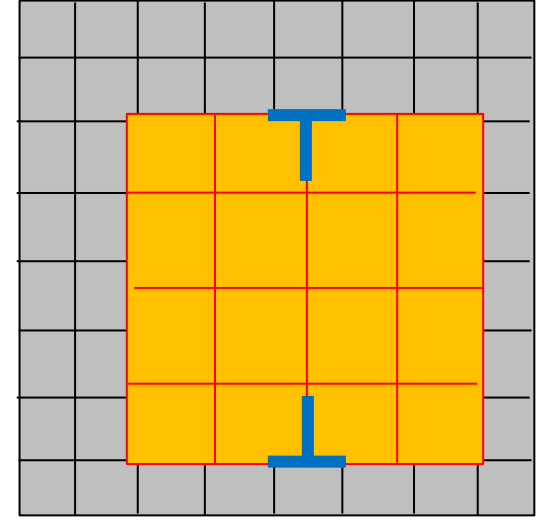
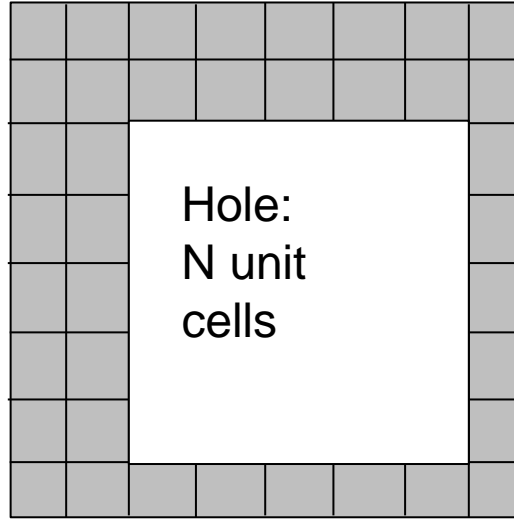
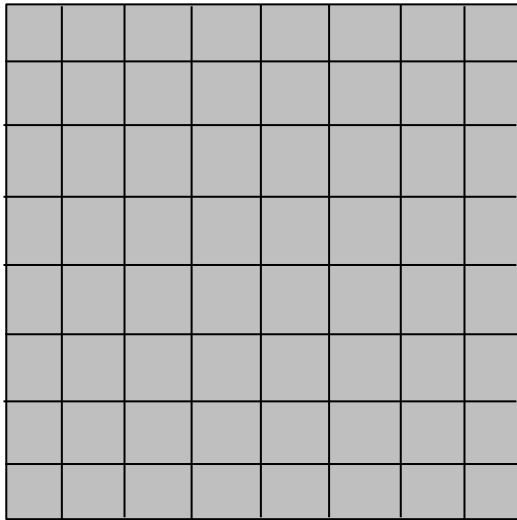
Compress nanorod



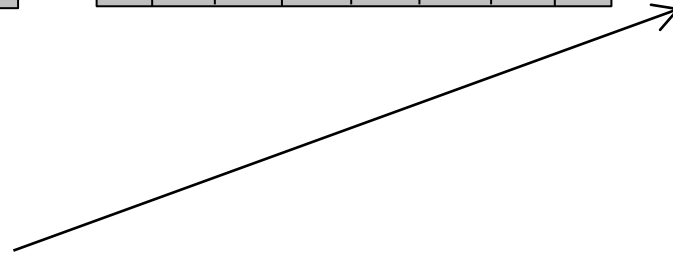
Insert nanorod and relax

Coherent

TEM – Nanorod Self-Assembly: Scenario 2



Nanorod:
N-1 unit cells

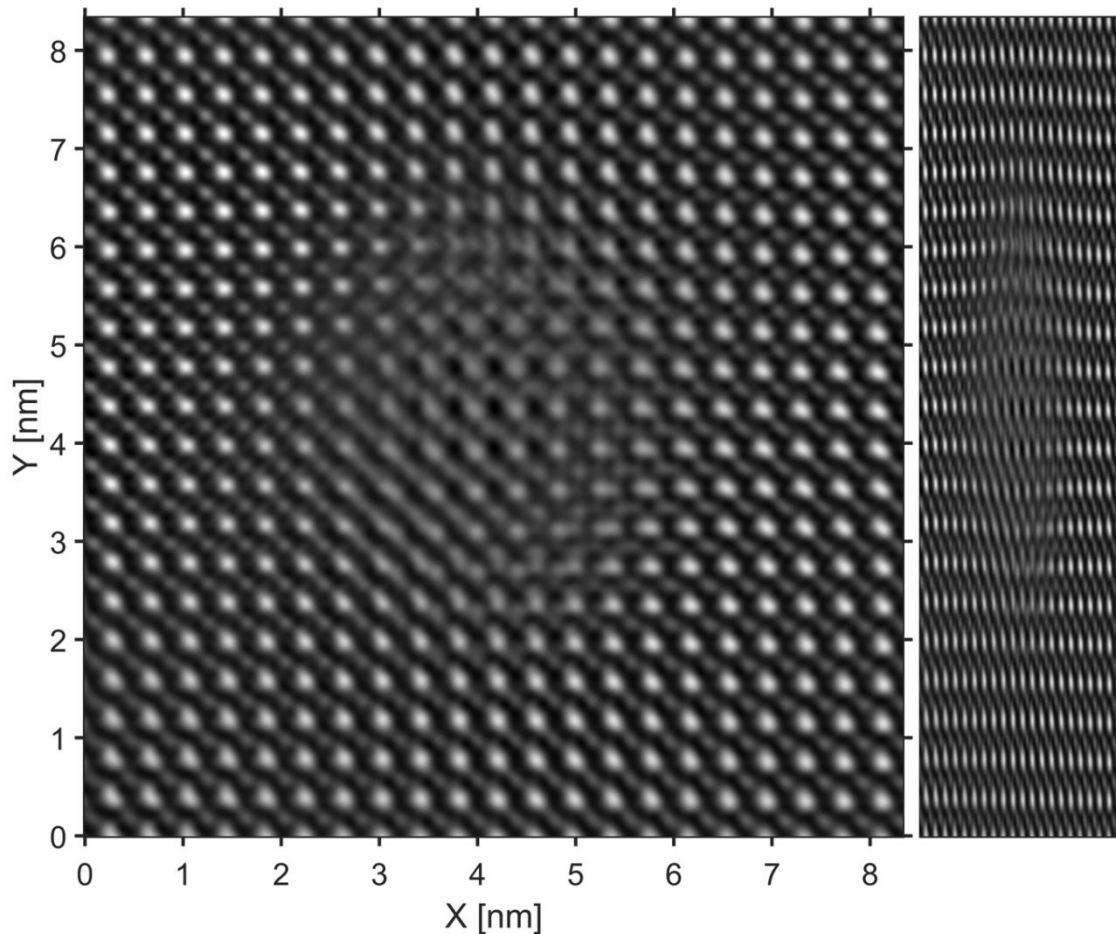


Minimal
compression to
match hole

Insert nanorod and
relax:

Minimized strain +
misfit dislocations

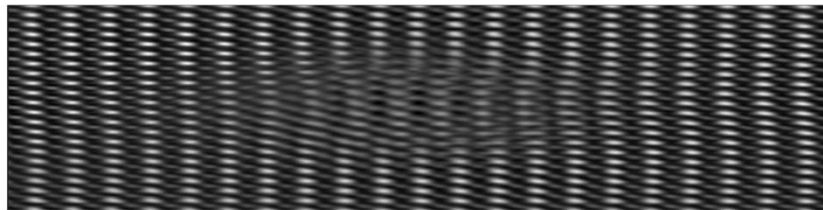
Semi-Coherent



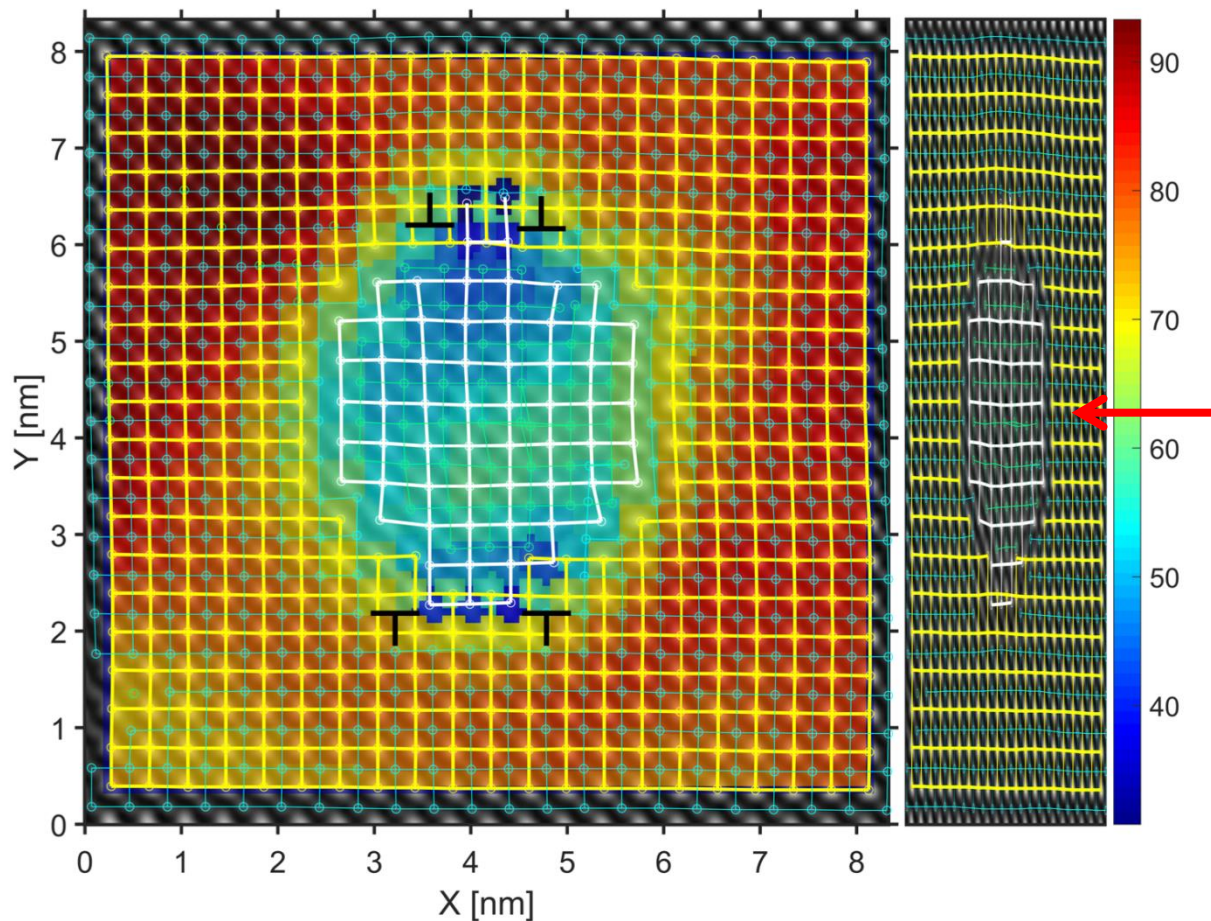
Plane view TEM:

BZO Nanorod in REBCO

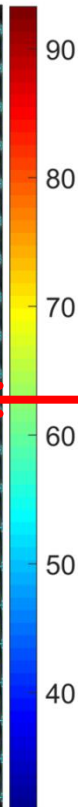
← Coherent in Y direction
(8 unit cells BZO,
8 unit cells REBCO)



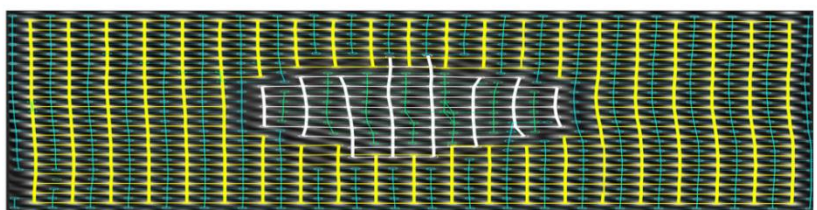
← Semi-Coherent in X
direction
(7 unit cells BZO,
8 unit cells REBCO)

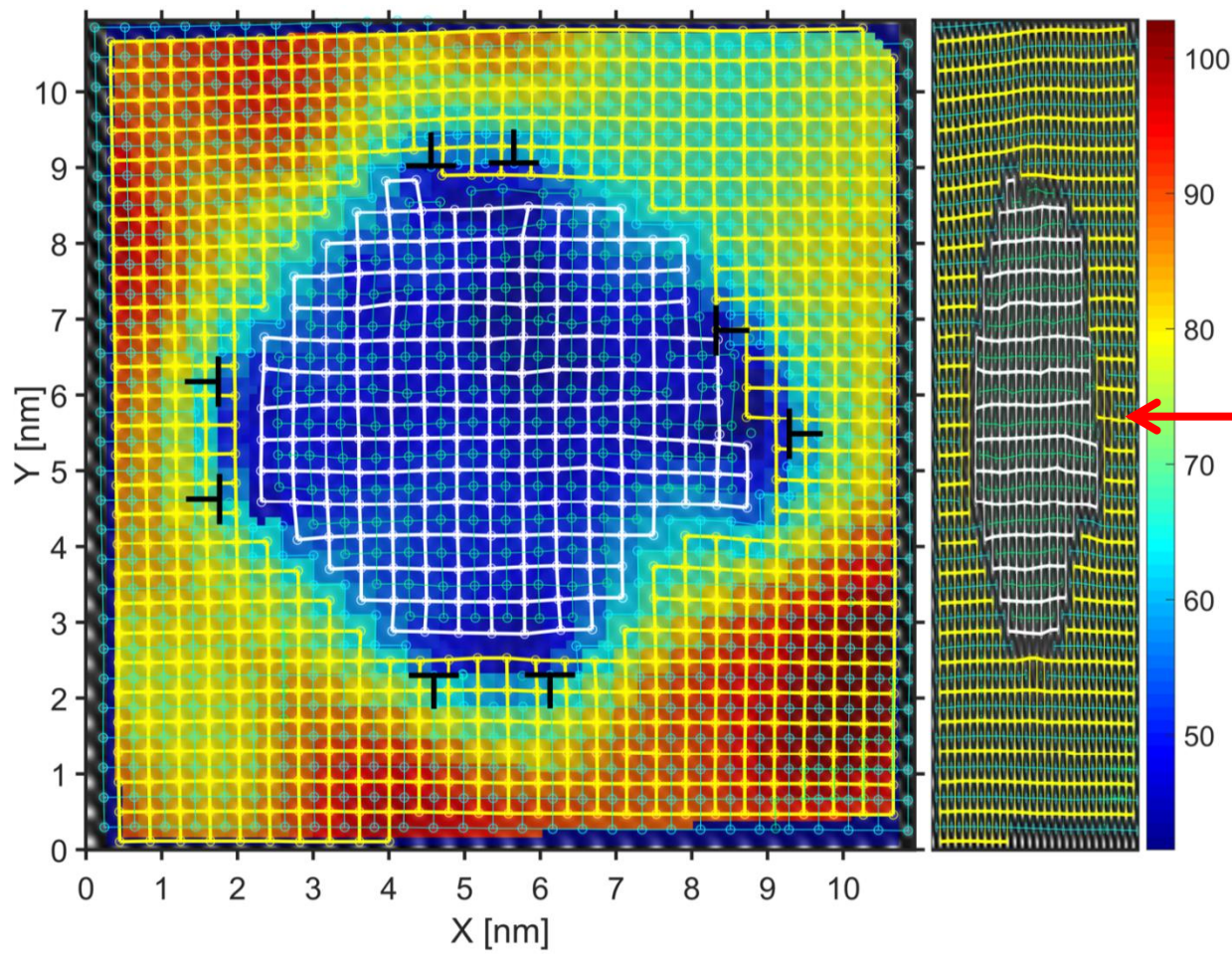


Yellow – peak pair (Ba-RE REBCO columns)
 Cyan – peak pair (Cu REBCO columns)
 White – peak pair (Ba BZO columns)



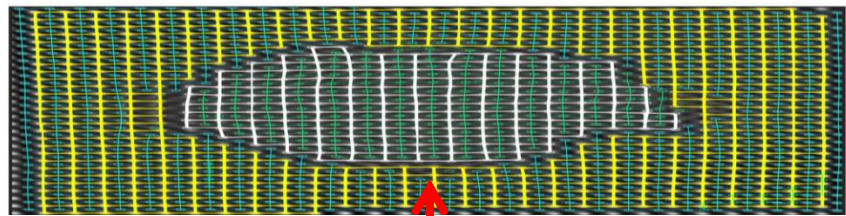
Classify as I-0 type:
 (number of antiphase lines or missing unit cells in x and y directions)



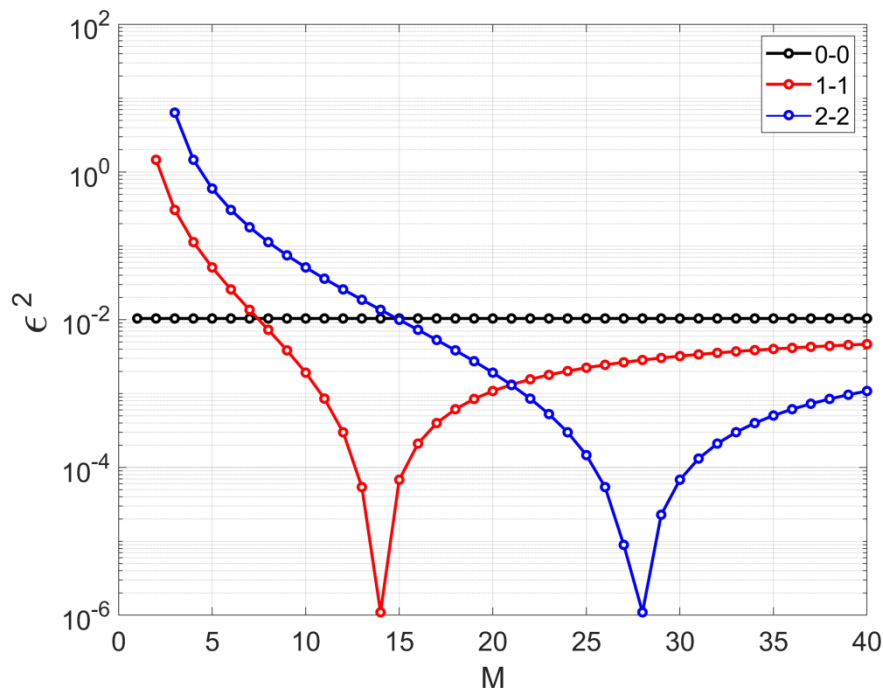


Classify as I-I type:
 (number of antiphase lines or missing unit cells in x and y directions)

NOTE: I-I size larger than I-0



Minimization of Mismatch strain:



a_M and a_N - lattice parameters
(matrix and nanorod)

$$k = a_M/a_N$$

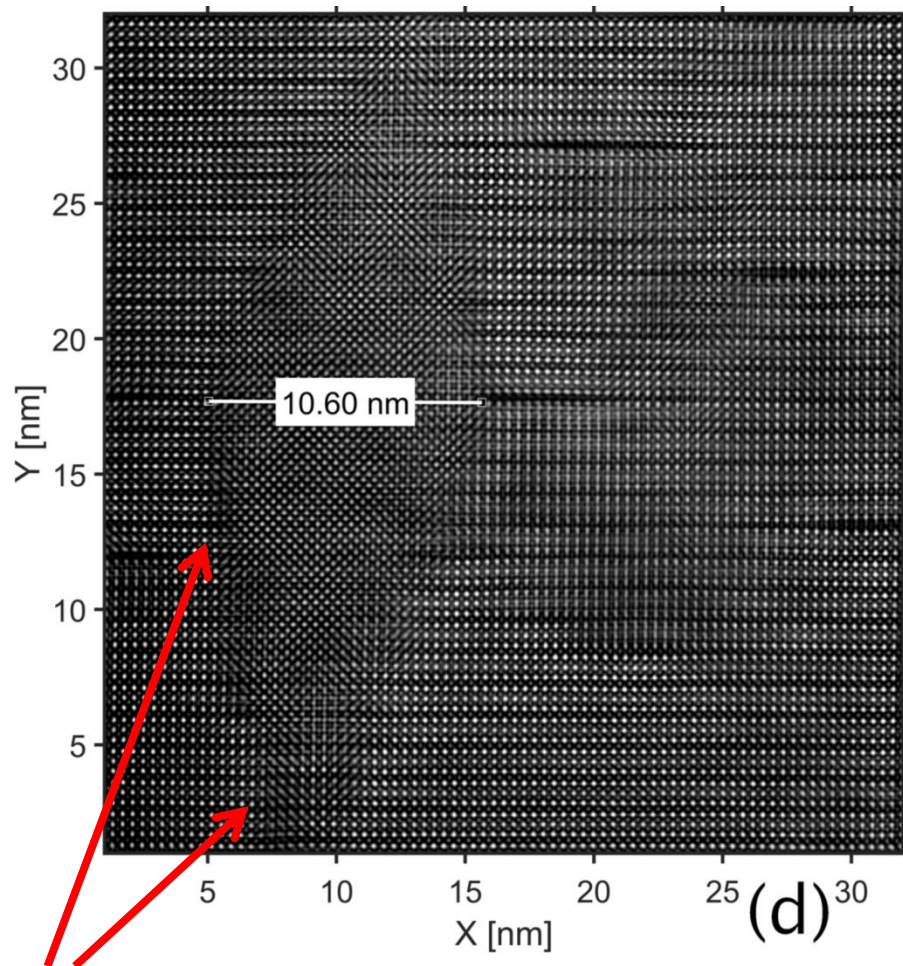
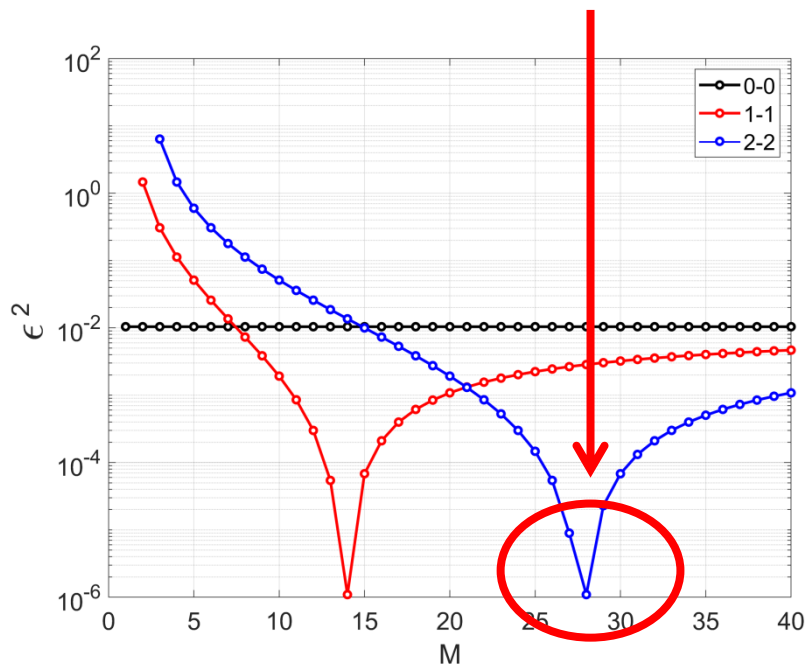
Matrix hole M unit cells
Nanorod N = M - P unit cells

Mismatch strain:

$$\epsilon = \frac{M}{M - P} k - 1$$

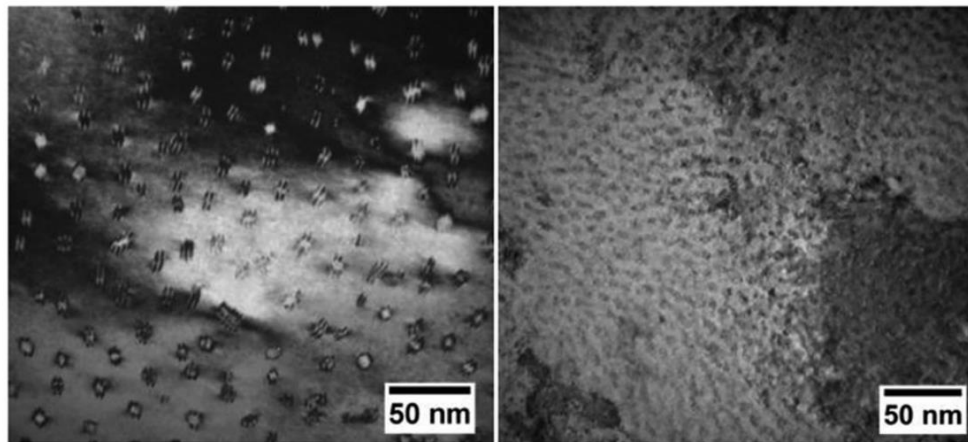
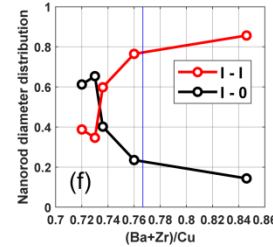
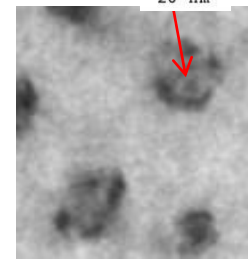
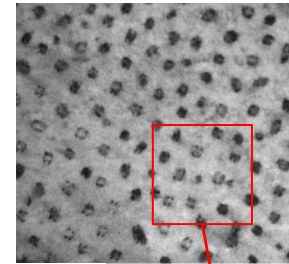
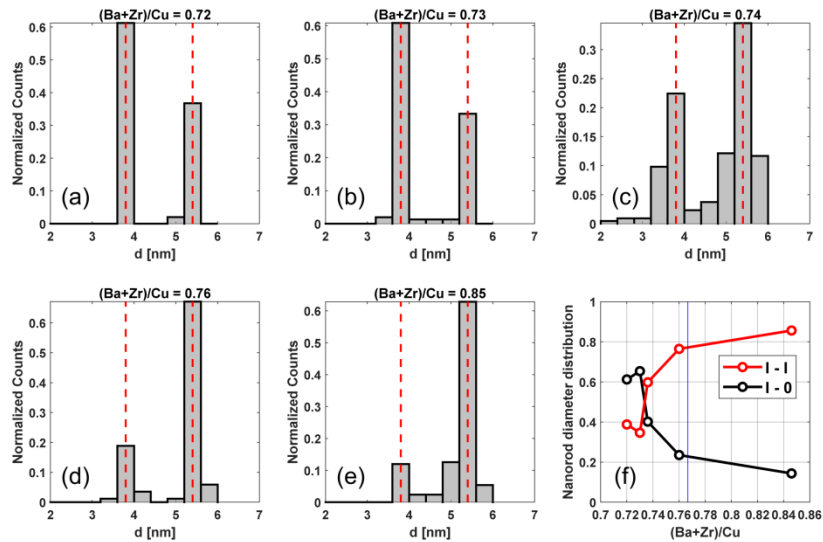
Deep minima in strain for ~14
and 28 unit cells.

Where is the II-II type?



Bottleneck modulation in BZO diameter: from I-I to II-II back to I-I

Nanorods assume discrete sizes: Bimodal Distribution of Nanorod Diameter



(a)

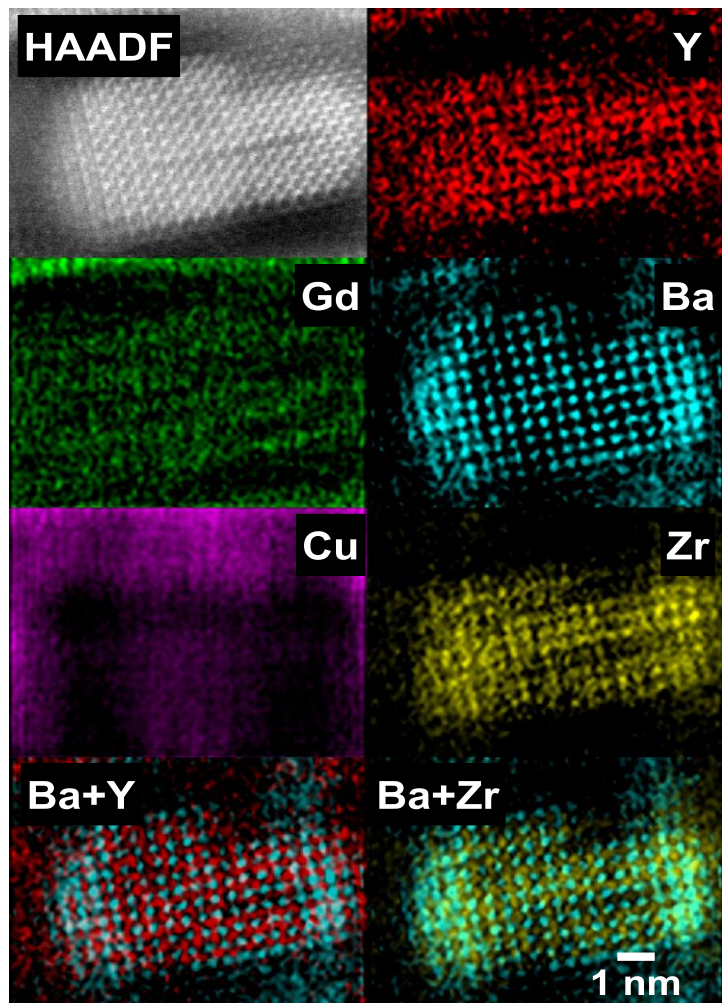
(b)

a.) nominal 25% Zr
b.) nominal 11% Zr

**Amount of dopant alone
does not determine
nanorod density.**

Nanorod type is important

Dopant amount alone does not control amount of nanorods (#2):



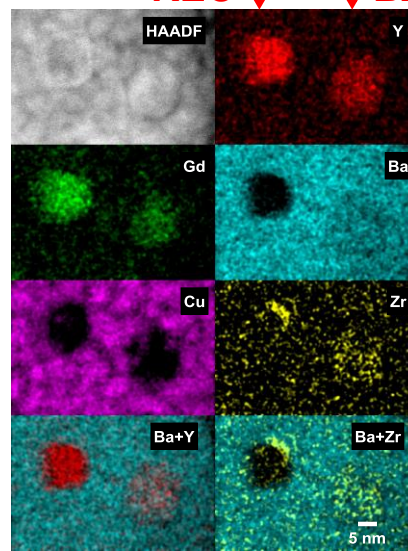
RE elements dissolve in BaZrO₃ !

This forms BaZr_{1-x}RE_xO₃

For every RE dissolved, we increase amount of Ba(M,RE)O₃.



REO ↓ ↓ BZO

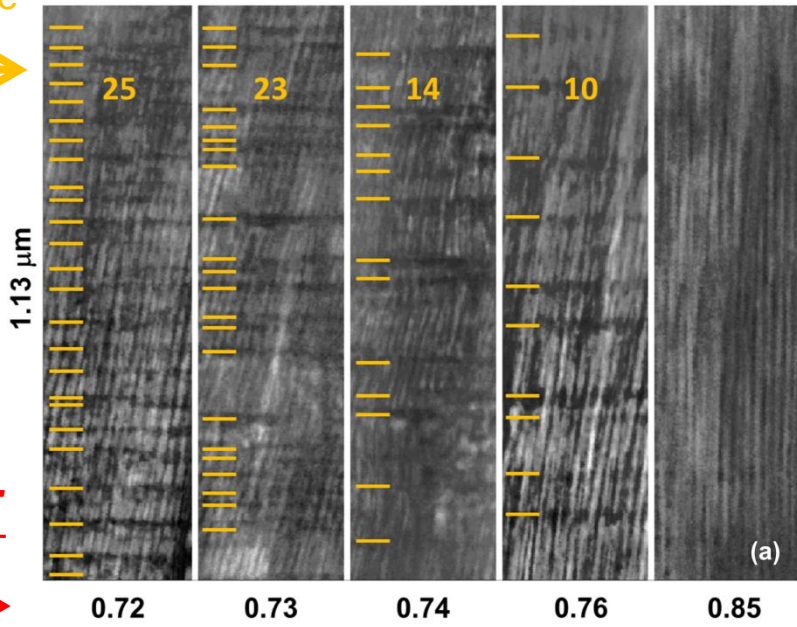


Where do excess RE and Ba come from?

Dopant amount alone does not control amount of nanorods

Where do excess RE and Ba come from?

RE₂O₃ precipitate arrays

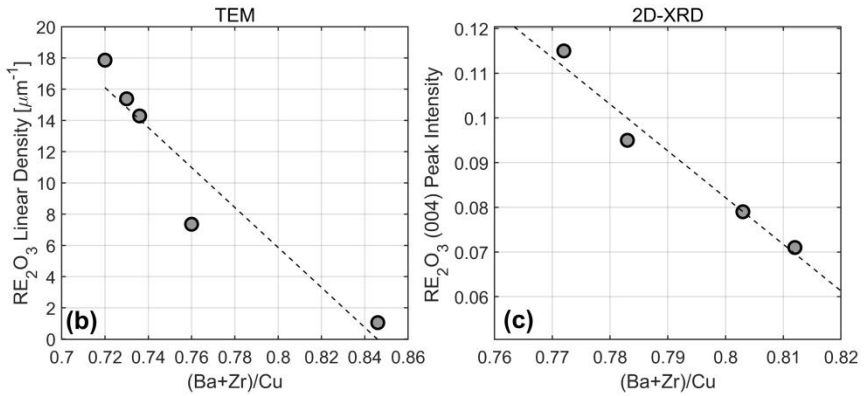


$\frac{Ba + Zr}{Cu}$

1.) Ba non-stoichiometry.

Variable BZC = $\frac{Ba+Zr}{Cu}$ metric (Zr=constant):

Increase in BZC results in depletion of REO precipitates



Dopant amount alone does not control amount of nanorods

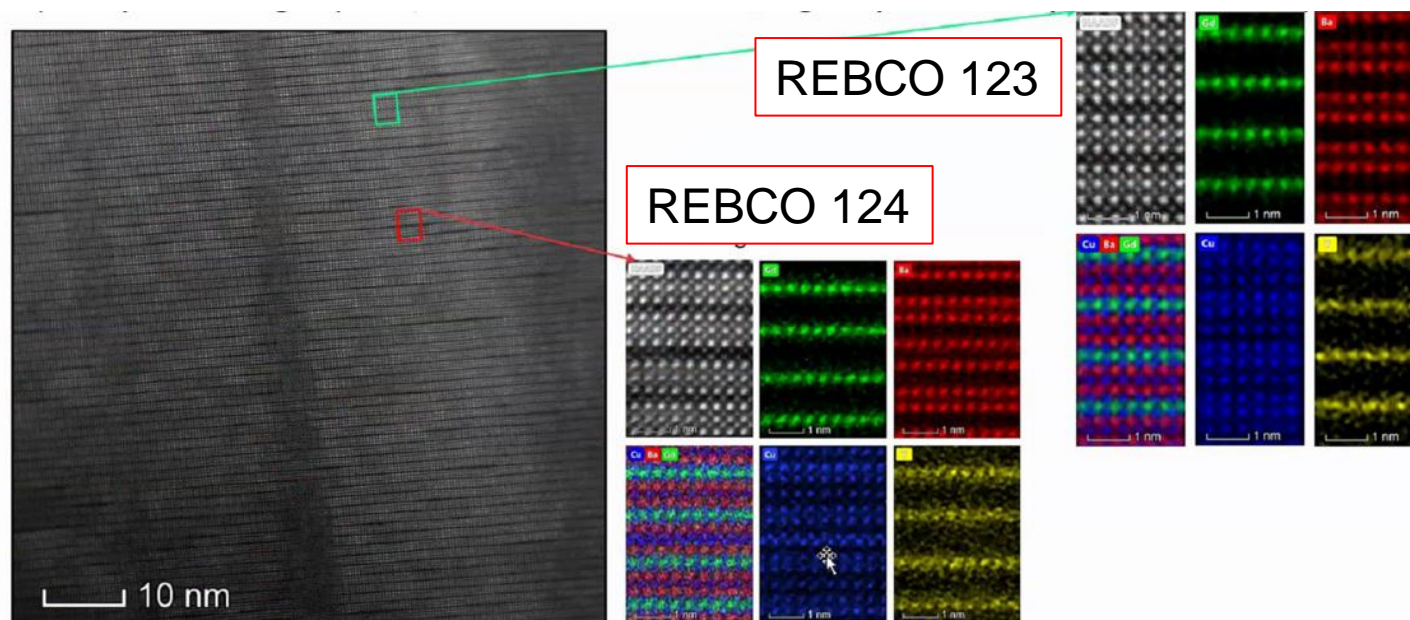
Where do excess RE and Ba come from?

2.) Consume stacking faults:

$3 \text{ REBCO}(124) = 4 \text{ REBCO}(123) + 1 \text{ RE} + 2 \text{ Ba}$

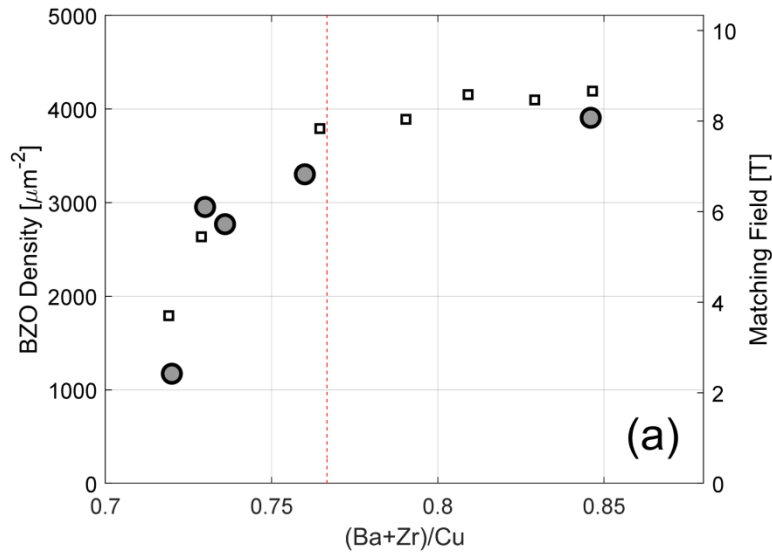
124 stacking faults accommodate lattice mismatch along c direction.

Depletion of 124 will affect c-axis mismatch strain



HV	Aperture	Probe Current	Camera Length	Image Size	Pixel size	Dwell Time	Acquisition
200 kV	50 μm (C2)	70 pA	115 mm	115x161 px/82x161 px	32 μm	15 μsec	10 min

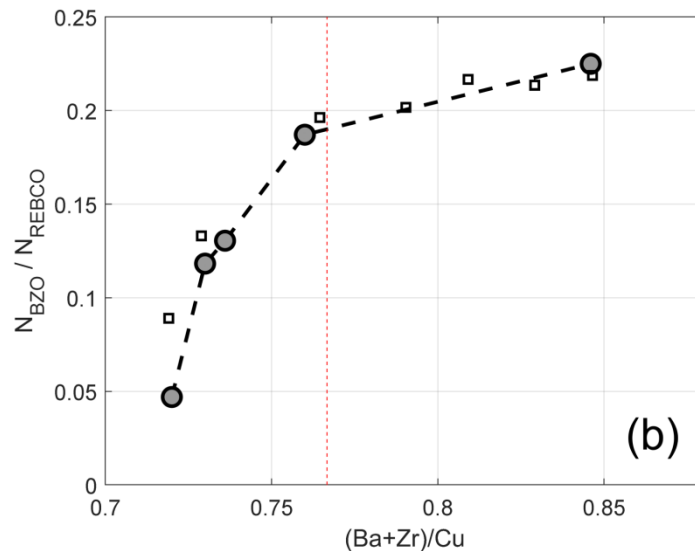
Result: wide range of nanorod densities and in-field performances for same nominal amount of M dopant



All samples have 15% Zr addition (nominal).

Vary BZC content =>

Nanorods vary from <5% to ~23% (u.c. fraction)



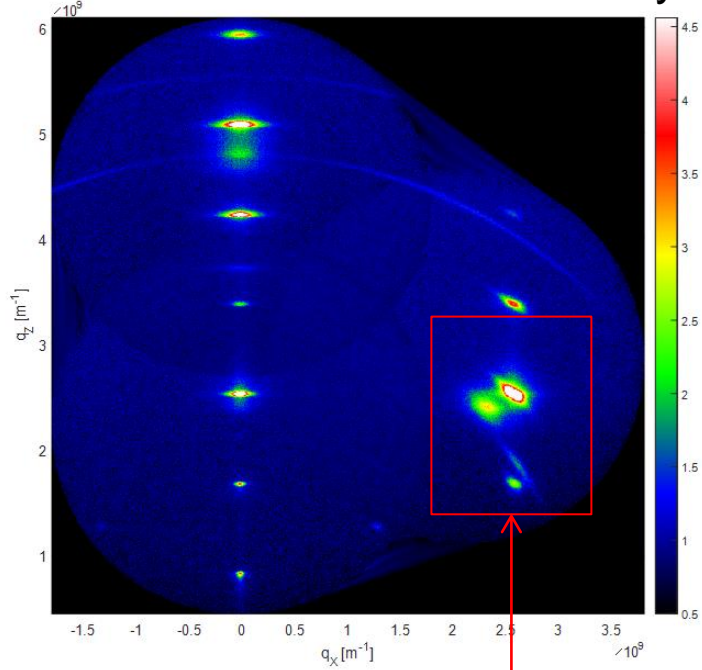
Quick, nondestructive characterization of nanorod density and in-field performance is vital for both:

- 1.) process control
- 2.) conductor utilization

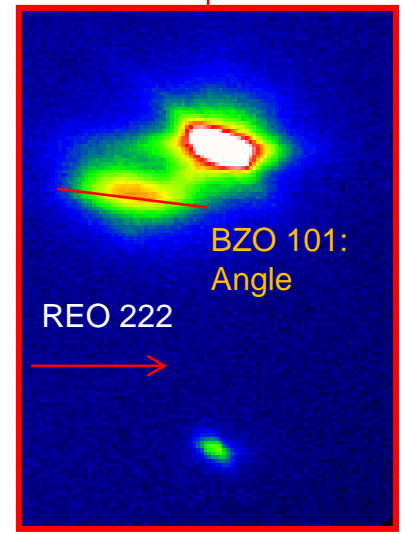
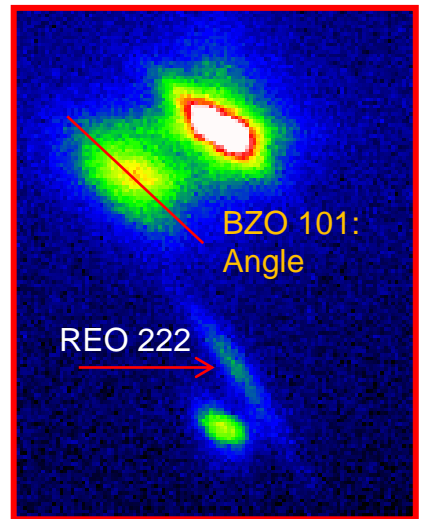
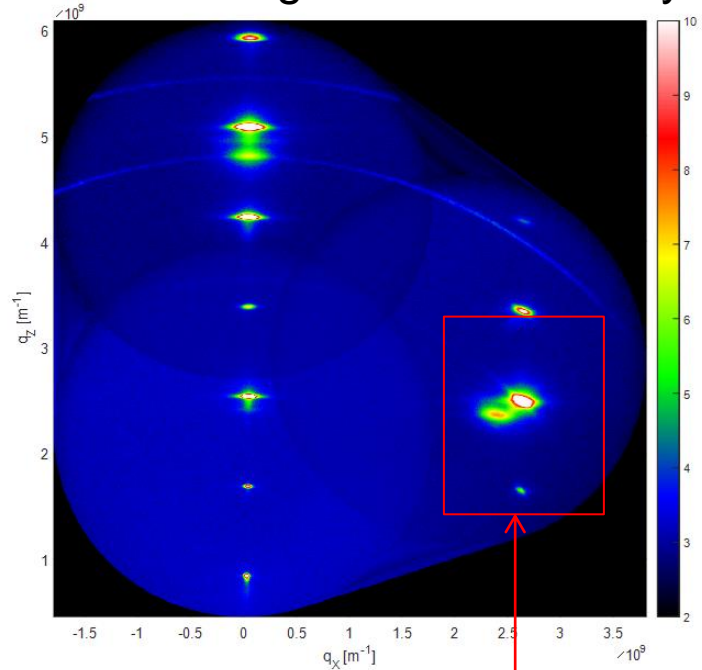
Nondestructive Evaluation:

1.) 2D-XRD

15% Zr – low nanorod density



15% Zr – high nanorod density



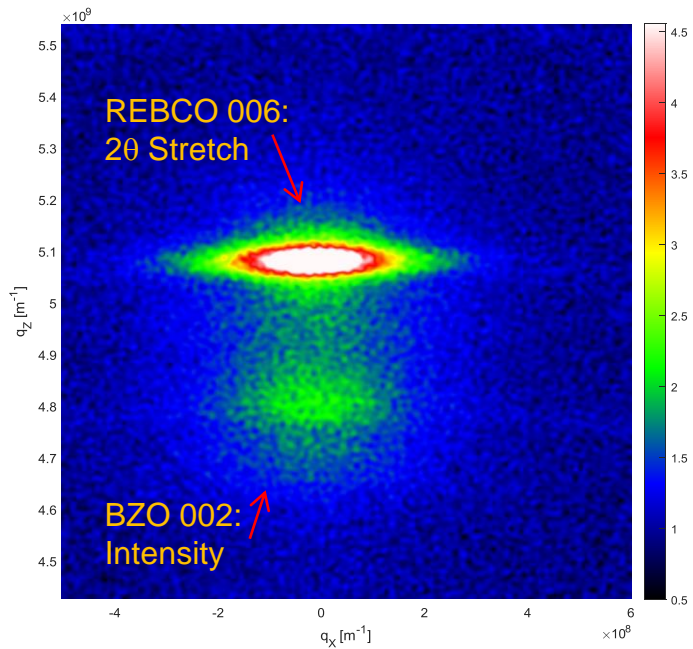
- 1.) **Streak angle of BZO 101:**
 - Along 2θ left
 - Perpendicular to c-axis right

- 2.) **REO 222**
 - Strong left
 - Absent right

Consistent with TEM:

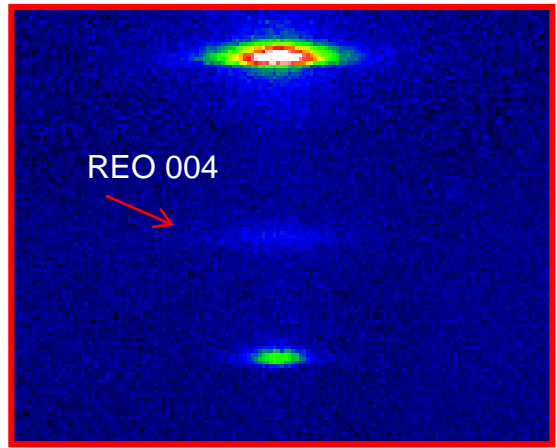
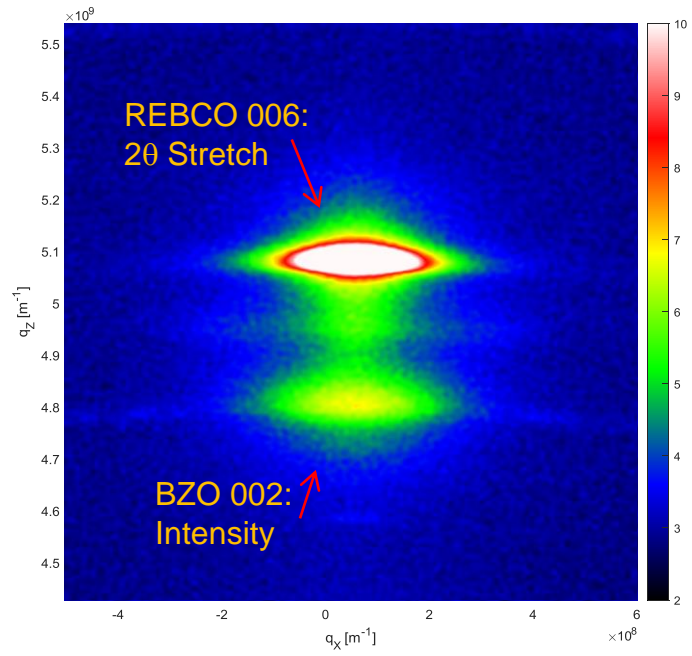
- Streak angle right = sinc broadening
- REO – consumed at high nanorod density

15% Zr – low nanorod density



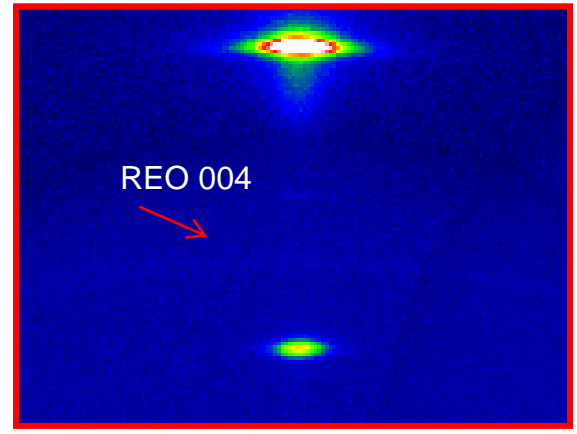
- 1.) REBCO 006 2θ stretch
- Increased (right)
- 2.) BZO 002 Intensity
- Increased (right)
- 3.) REO 004
- Decreased (right)

15% Zr – high nanorod density

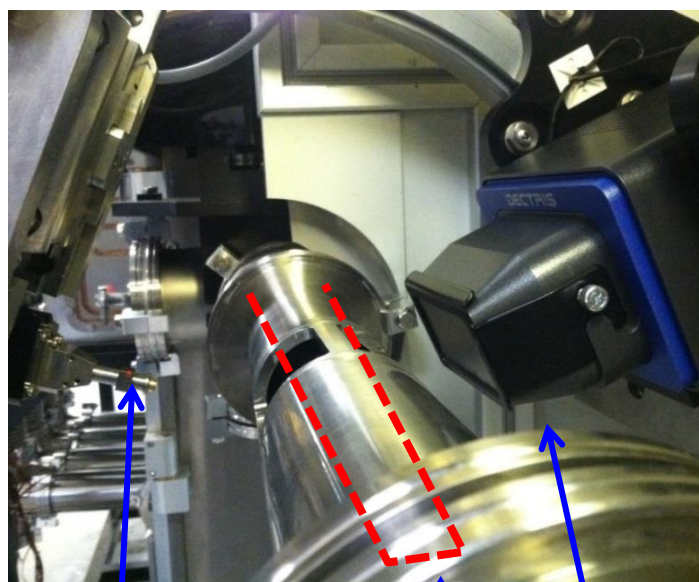


Consistent with TEM:

- Loss of 124 s.f.
- More BZO domains
- REO consumed



Inline Implementation: 2D-XRD

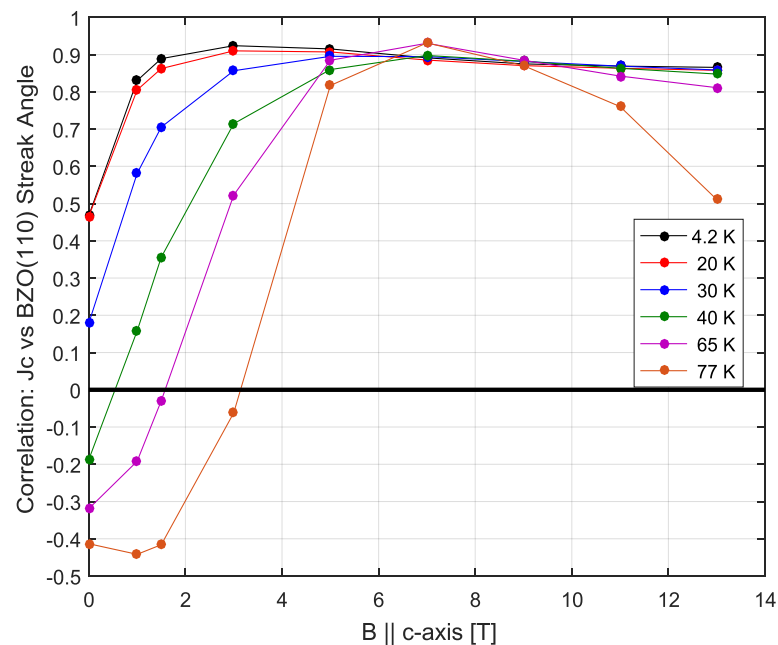


X-ray Source

Tape path in A-MOCVD

2D Detector

2D-XRD integrated inline with A-MOCVD

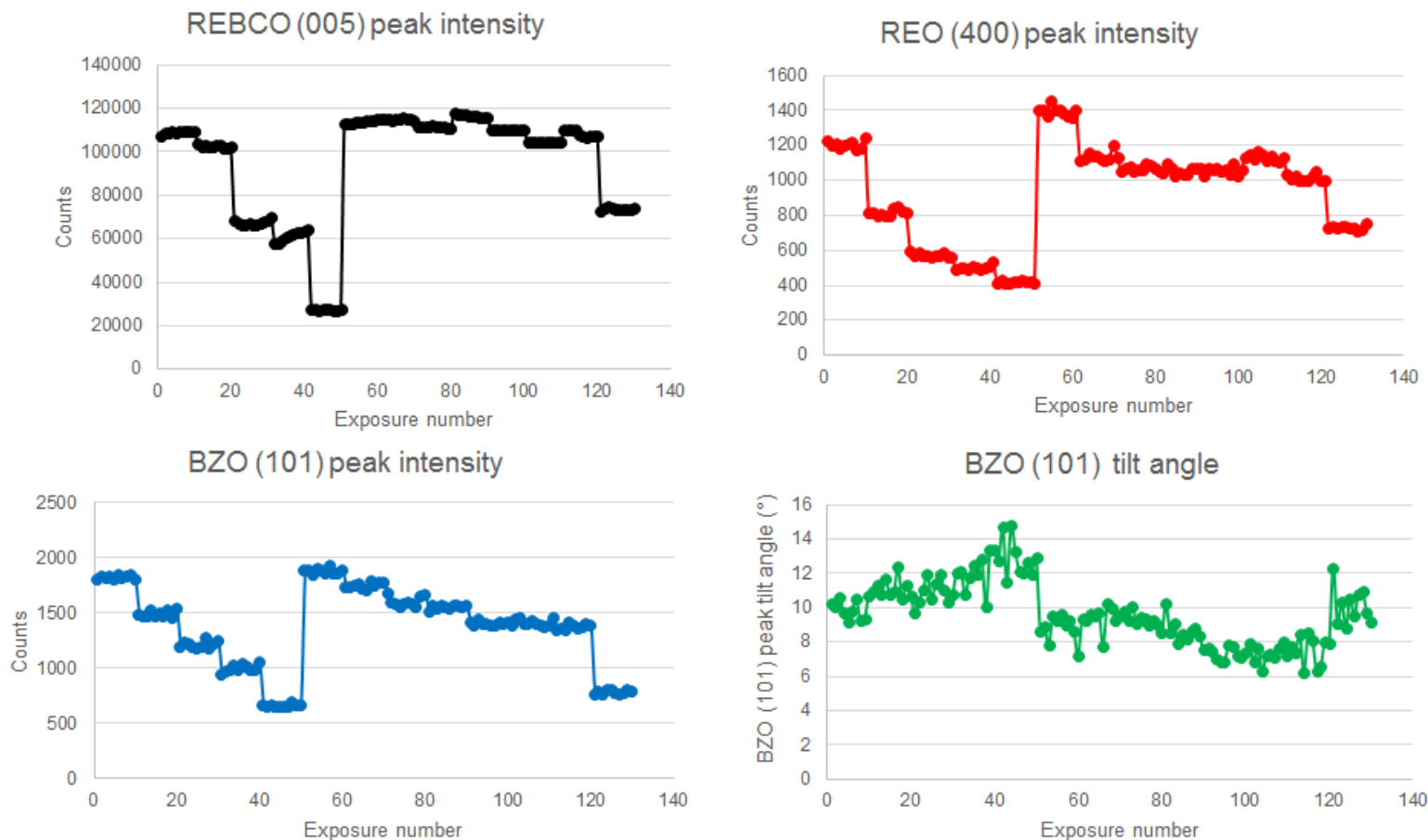


Pearson Correlation – BZO streak angle vs $J_c(B, T)$

Streak angle correlates well with J_c at lower temperatures:

- At 4.2, 20 K from 2 T
- At 30, 40 K from 5 T

Inline Implementation: 2D-XRD



Continuous inline measurement at feature extraction

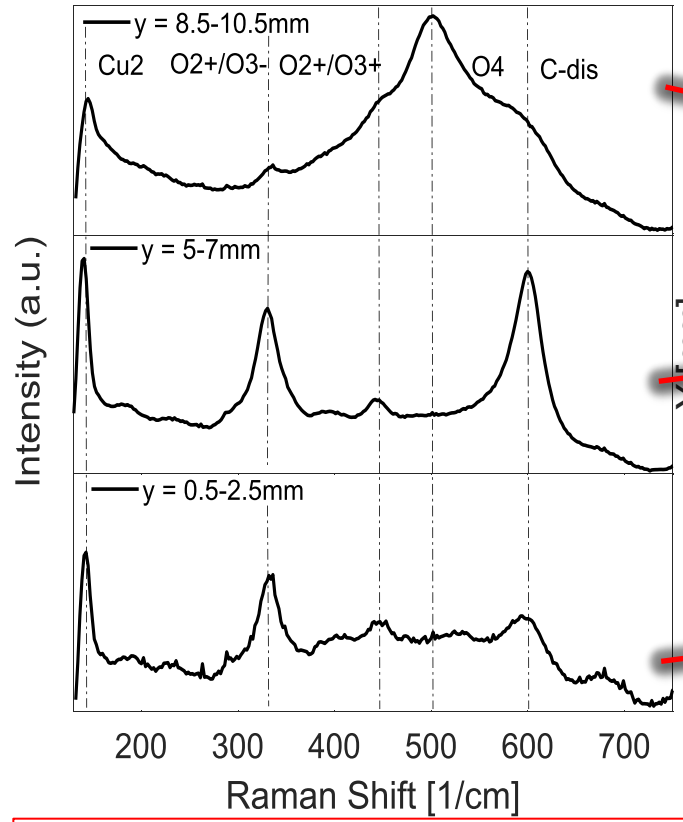
Nondestructive Evaluation:

2.) Scanning Raman

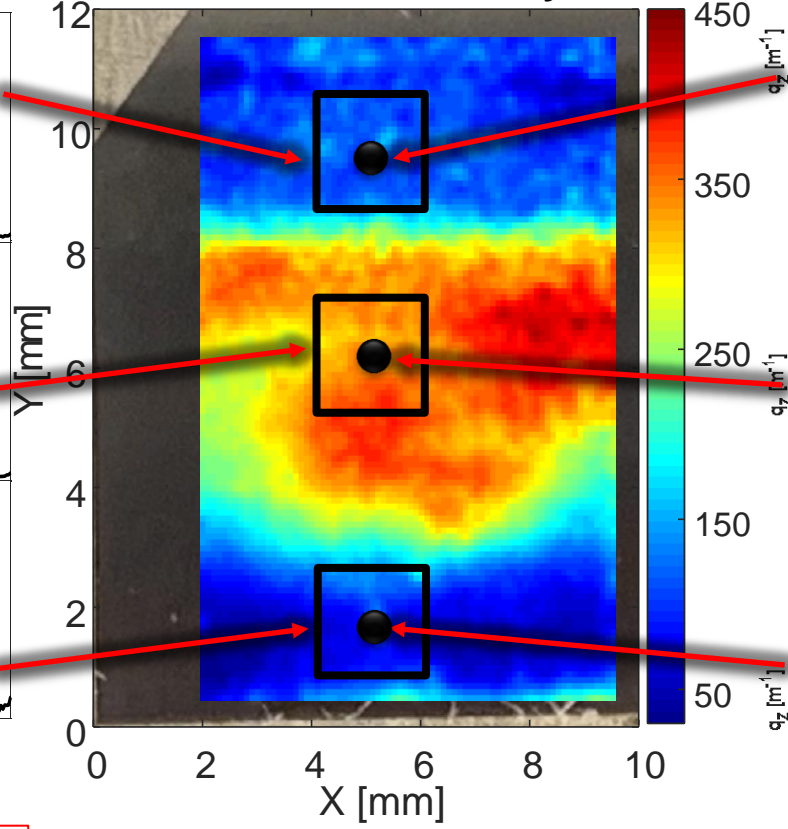
Scanning Raman Capabilities Demonstrated for Defect Detection

Raman Integrated Spectra

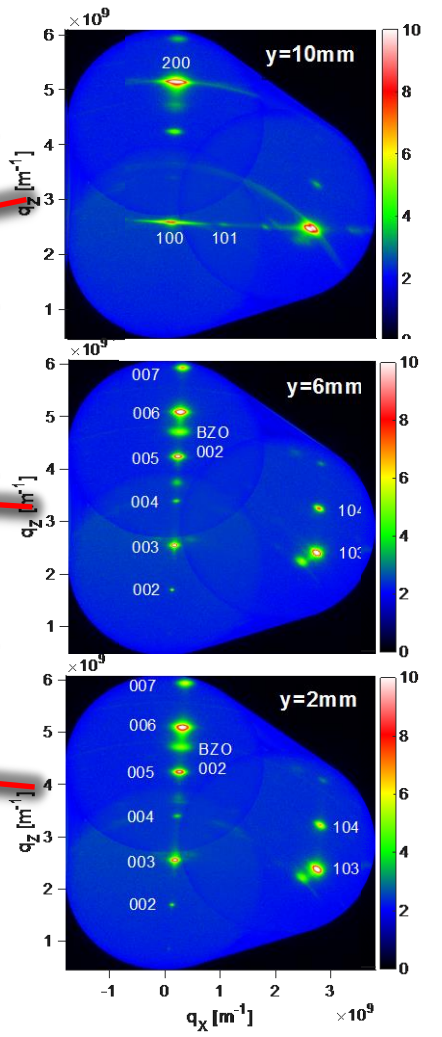
x = 4-6mm



O2+/O3- Intensity



2D-XRD

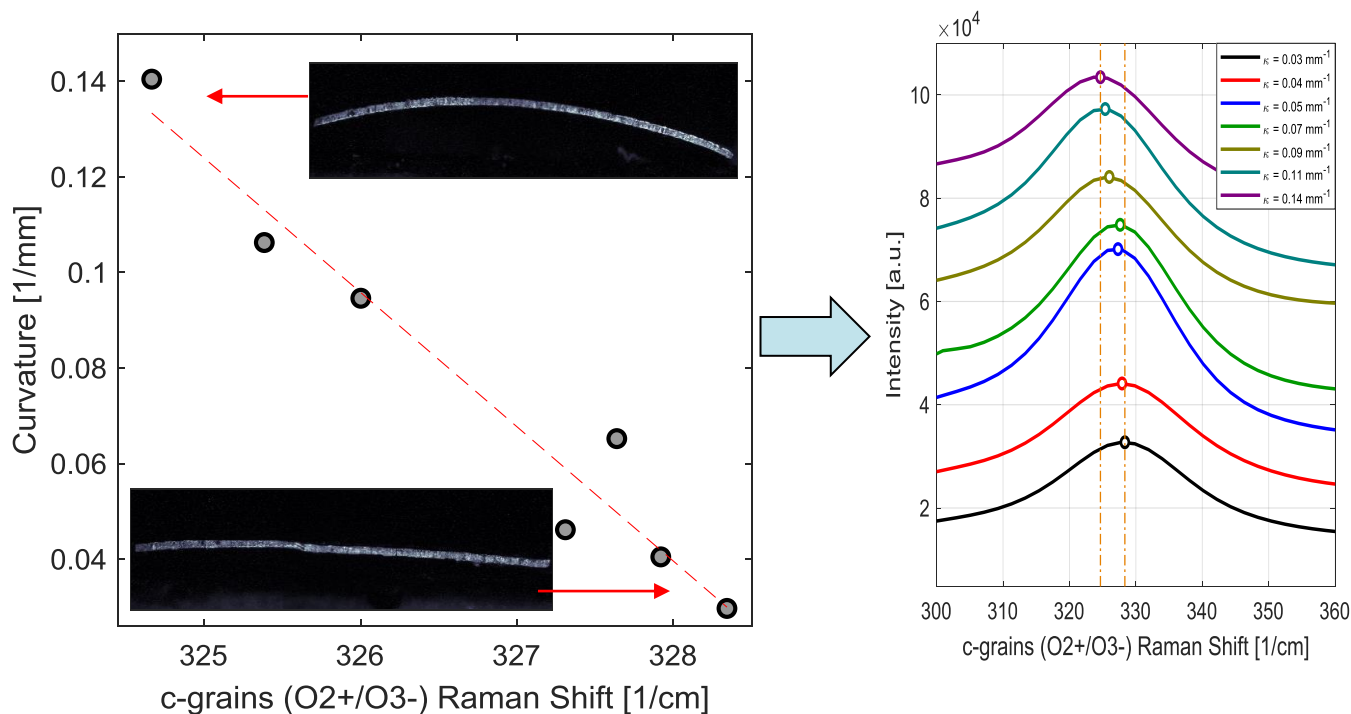


N. Castaneda, G. Majkic, and F. C. Robles, "Scanning Raman spectroscopy for inline characterization of 2G-HTS conductors," *Superconductor Science and Technology*, vol. 34, no. 3, 2021.

NEXT: Can we characterize pinning center density?

Can we characterize pinning center density?

Strain: Tape Curvature vs O₂+/O₃- Raman Shift:



Higher nanorod density =
higher residual strain =
induced curvature

Can be detected via
O₂/O₃- peak shift:

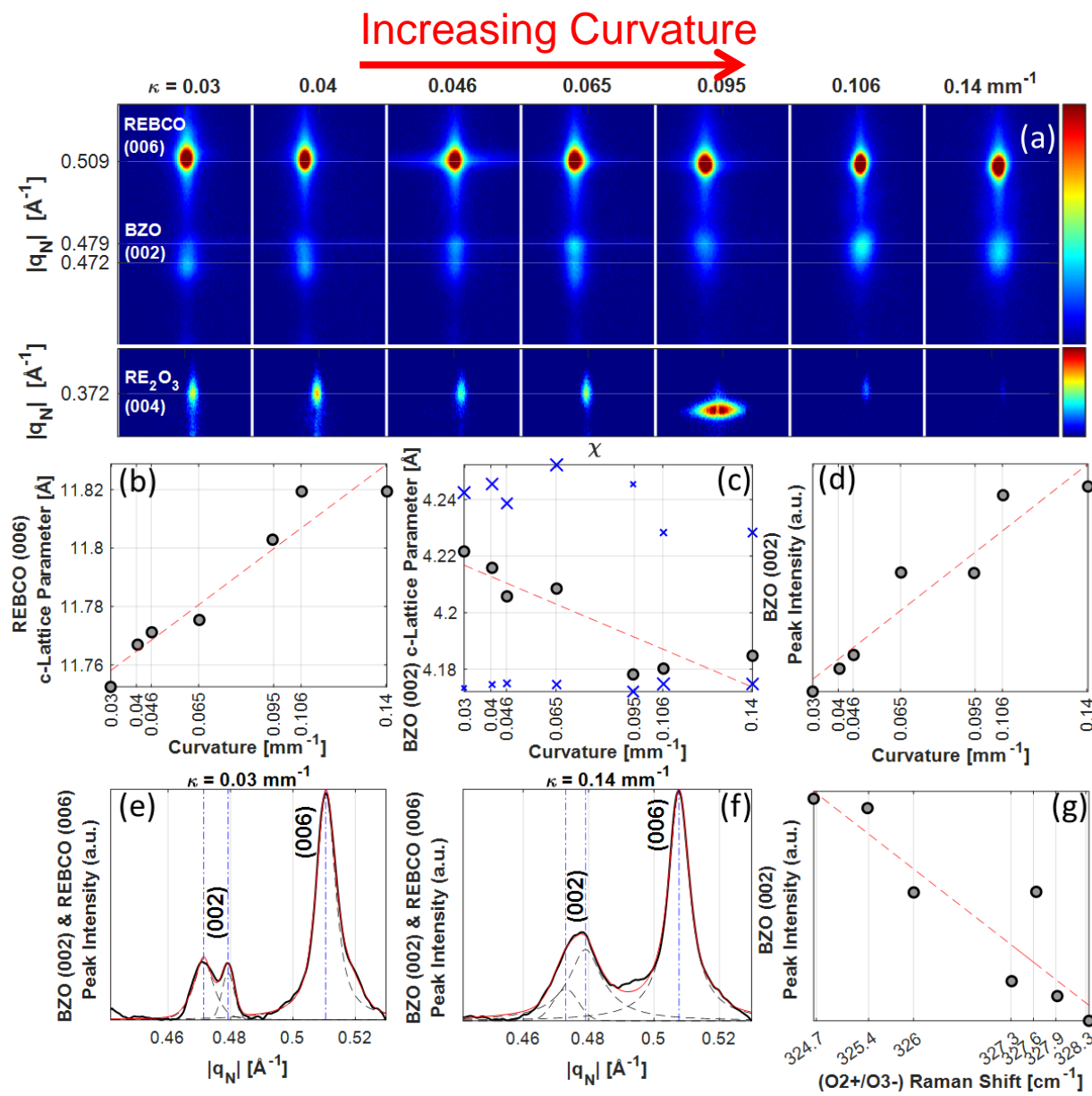
Strong linear correlation between measured curvature and Raman shift

Comparison with 2D-XRD on same samples

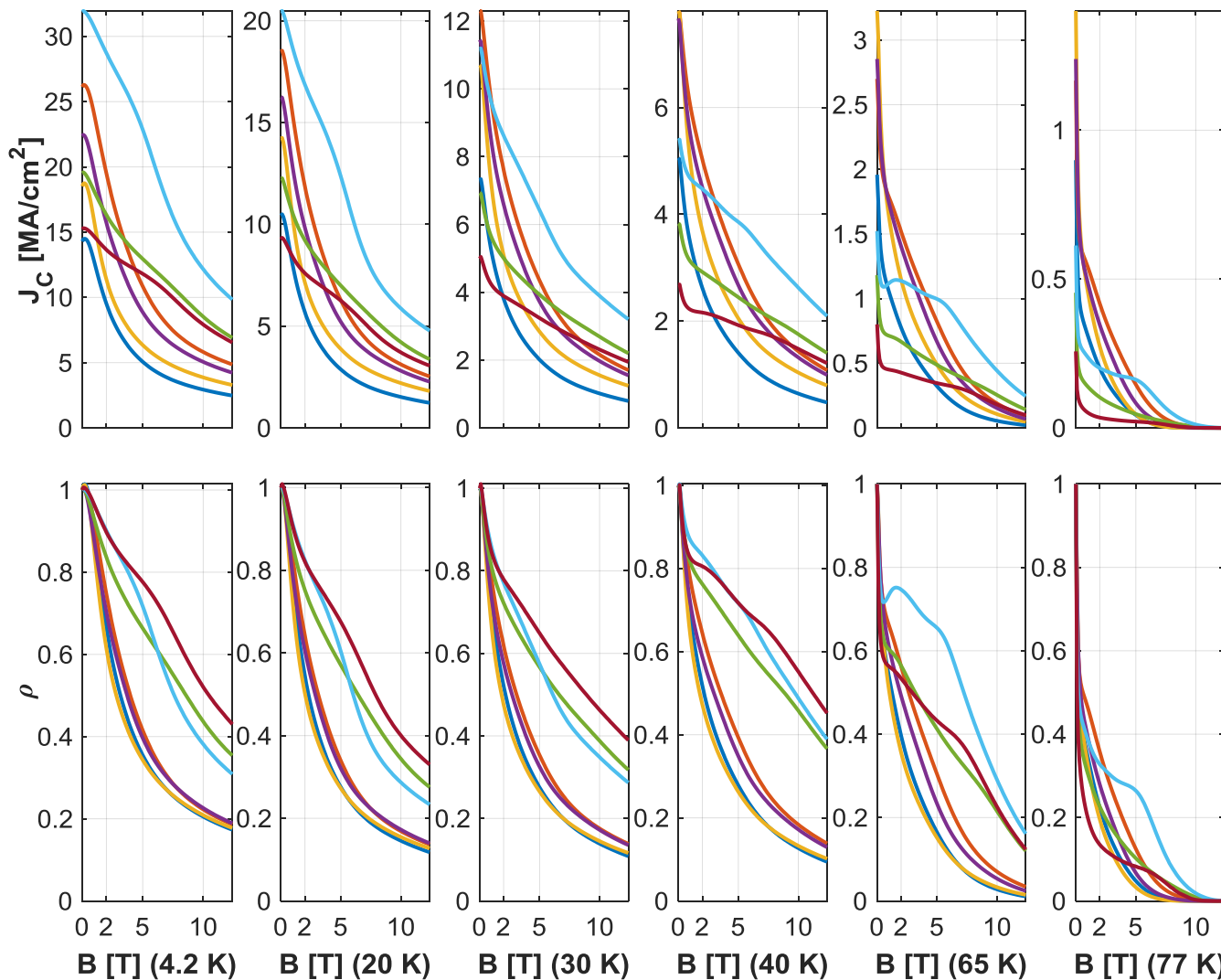
- REBCO c-axis lattice parameter increase with curvature and BZO(002) intensity.
- BZO c-axis bimodal, (4.23 and 4.17 Å) – more 4.17 at higher curvature.
- REO intensity decrease with curvature
- Strong linear trend between BZO(002) intensity and Raman 02/03- shift.

Clear linear trend between BZO (002) integral and O2/O3- Raman shift:

Use Raman to evaluate nanorod density



Can Raman O2/O3- Predict $J_c(B, T)$ and Retention $\rho(B, T)$?

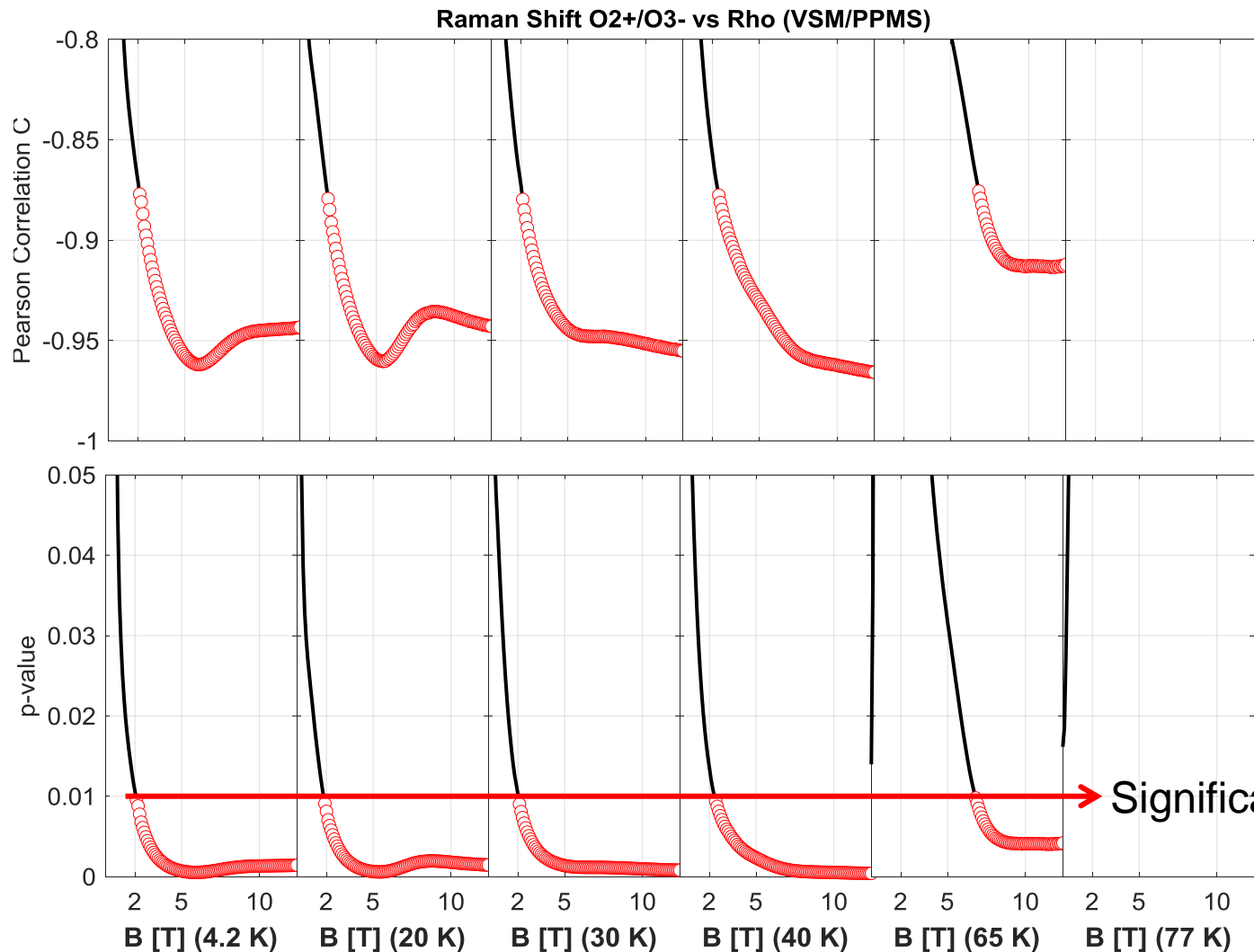


Critical Current Density
 $J_c(B, T)$

Retention Factor
 $\rho(B, T) = \frac{J_c(0, T)}{J_c(B, T)}$

Both $J_c(B, T)$ and $\rho(B, T)$ vary widely over the selected samples

Can Raman O2/O3- Predict $J_c(B,T)$ and Retention $\rho(B,T)$?



For $J_c(B,T)$, no strong correlation

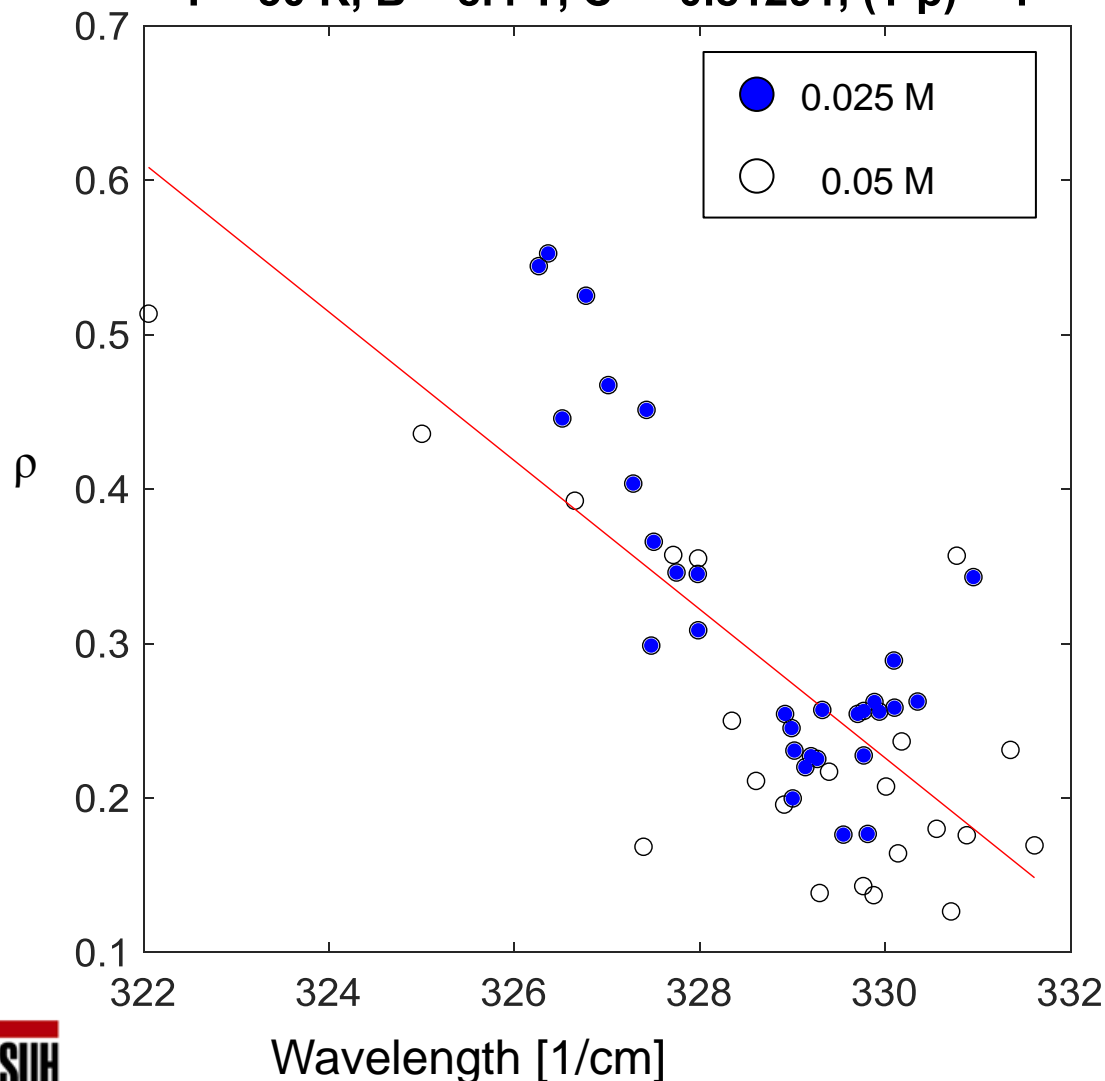
However, for Retention $\rho(B,T)$:

strong negative correlation
(4.2-40K)
(~2 -14 T)

Significance Level: $p < 0.01$

Cross Validation over a Large Data Set

$T = 30 \text{ K}$, $B = 8.4 \text{ T}$, $C = -0.81291$, $(1-p) = 1$



Set of 53 samples.

A mixture of 0, 5 and 15% Zr or Hf.

Also, 0.025 and 0.05 M molarity

Correlation:

$C = -0.81$
 $(p < 0.01)$

Raman can measure
retention factor

(proportional to pinning
center density)

Thank you